

## Supplementary Information

### Semimetallic electrical properties of rock-salt type LaBi thin film grown by solid-phase reaction of La/Bi multilayer precursor

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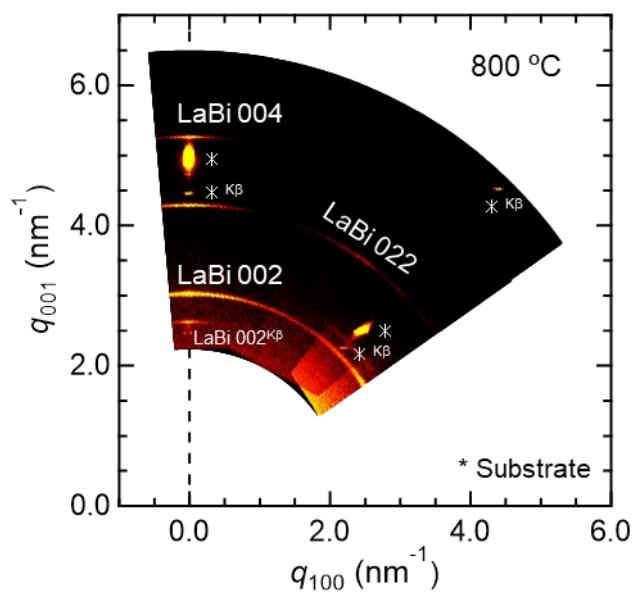
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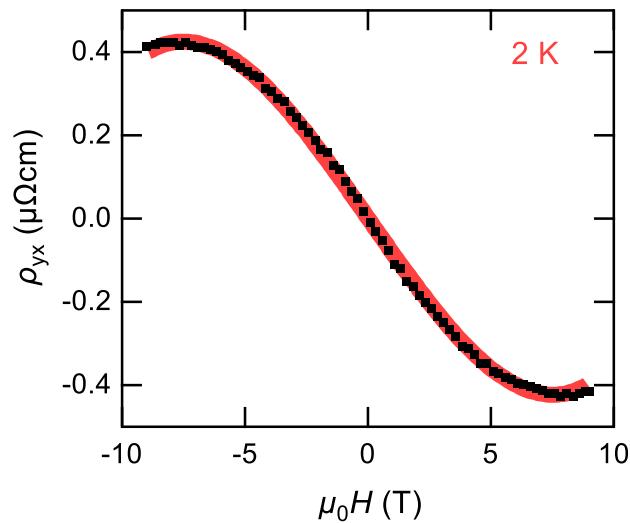
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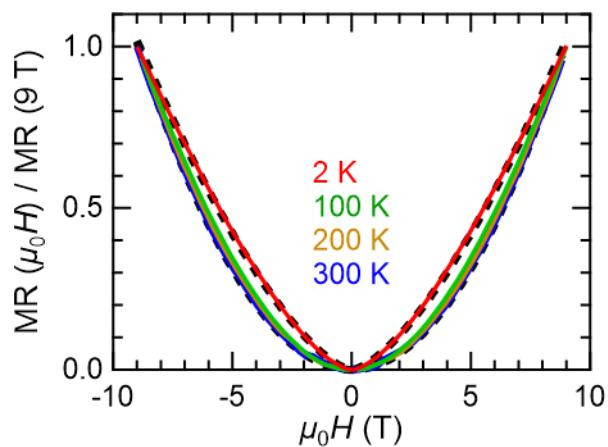
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**Fig. S1** Two-dimensional X-ray diffraction pattern for LaBi thin film with  $T_g = 800 \text{ } ^\circ\text{C}$ .



**Fig. S2** Magnetic field dependence of Hall resistivity for LaBi thin film at 2 K. Red curve denotes the fitting result using two-carrier model.



**Fig. S3** Normalized magnetoresistance (MR) at 2, 100, 200, and 300 K. Dashed curves denote fitting results with  $(\mu_0 H)^{1.5}$  and  $(\mu_0 H)^2$  dependence for 2 K and 100–300 K, respectively.

**Table. S1** Electron carrier density ( $n_e$ ), hole carrier density ( $n_h$ ), electron mobility ( $\mu_e$ ), and hole mobility ( $\mu_h$ ) for LaBi.

	$n_e$ (/cm <sup>3</sup> )	$n_h$ (/cm <sup>3</sup> )	$\mu_e$ (cm <sup>2</sup> /Vs)	$\mu_h$ (cm <sup>2</sup> /Vs)	Ref.
This study (2K)	$1.11 \times 10^{20}$	$1.25 \times 10^{20}$	$5.77 \times 10^2$	$5.26 \times 10^2$	-
Bulk (2 K)	$6.12 \times 10^{19}$	$6.09 \times 10^{19}$	$5.68 \times 10^3$	$5.88 \times 10^3$	1
Bulk (2 K)	$6.0(4) \times 10^{20}$	$6.0(3) \times 10^{20}$	$2.6(1) \times 10^4$	$3.1(1) \times 10^4$	2
Bulk (2 K)	$7.62 \times 10^{20}$	$7.56 \times 10^{20}$	$1.75 \times 10^4$	$1.89 \times 10^4$	3
Bulk (5 K)	$2 \times 10^{19}$	$1.9 \times 10^{19}$	$1.28 \times 10^4$	$1.26 \times 10^4$	4

## References in Supplementary Information

- 1 F. F. Tafti, Q. D. Gibson, S. Kushwaha, J. W. Krizan, N. Haldolaarachchige, R. J. Cava, *Proc. Natl. Acad. Sci.*, 2016, **113**, E3475.
- 2 S. Sun, Q. Wang, P.-J. Guo, K. Liu, H. Lei, *New J. Phys.*, 2016, **18**, 082002.
- 3 N. Kumar, C. Shekhar, S.-C. Wu, I. Leermakers, O. Young, U. Zeitler, B. Yan, C. Felser, *Phys. Rev. B*, 2016, **93**, 241106(R).
- 4 R. Singha, B. Satpati, P. Mandal, *Sci. Rep.*, 2017, **7**, 6321.